EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	8846	((568/665) or (568/669) or (568/655) or (568/656) or (526/247) or (526/318) or (430/270.1)).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2006/08/22 16:30
L2	66665	vinyl near2 ether	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/08/22 16:31
L3	2425	I1 and I2	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/08/22 16:31
L4	881136	cyclopentane or cyclohexane or norbornene or phenyl or benzene or tricyclodecane	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/08/22 16:33
L5	1902	13 and 14	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/08/22 16:33
L6	266277	fluorine	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/08/22 16:33
L7	1258	I5 and I6	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/08/22 16:34
L8	4368	I2 same I6	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/08/22 16:34
L9	196	I7 and I8	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/08/22 16:35

EAST Search History

L10	14490	resist near2 composition	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/08/22 16:35
L11	52	19 and 110	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/08/22 18:07
L12	252779	kobayashi.in. or maeda.in. or tsujishita.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/08/22 18:08
L13	313	I2 and I6 and I12	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/08/22 18:09
L14	109	18 and 113	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/08/22 18:10
L15	20	I10 and I14	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2006/08/22 18:11

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Welcome to STN International! Enter x:x

LOGINID:SSSPTA1204rxw

PASSWORD:

TERMINAL (ENTER 1, 2, 3, OR ?):2

```
NEWS
                 Web Page URLs for STN Seminar Schedule - N. America
NEWS
                 "Ask CAS" for self-help around the clock
NEWS 3
        FEB 27
                 New STN AnaVist pricing effective March 1, 2006
NEWS 4
        APR 04
                 STN AnaVist $500 visualization usage credit offered
NEWS 5 MAY 10
                 CA/CAplus enhanced with 1900-1906 U.S. patent records
                 KOREAPAT updates resume
NEWS 6 MAY 11
NEWS
    7
        MAY 19
                 Derwent World Patents Index to be reloaded and enhanced
                 IPC 8 Rolled-up Core codes added to CA/CAplus and
NEWS 8
        MAY 30
                 USPATFULL/USPAT2
NEWS 9
        MAY 30
                 The F-Term thesaurus is now available in CA/CAplus
NEWS 10
        JUN 02
                 The first reclassification of IPC codes now complete in
                 INPADOC
NEWS 11
        JUN 26
                 TULSA/TULSA2 reloaded and enhanced with new search and
                 and display fields
                 Price changes in full-text patent databases EPFULL and PCTFULL
NEWS 12
        JUN 28
NEWS 13
        JU1 11
                 CHEMSAFE reloaded and enhanced
NEWS 14
        JUl 14
                 FSTA enhanced with Japanese patents
NEWS 15
        JUl 19
                 Coverage of Research Disclosure reinstated in DWPI
NEWS 16
        AUG 09
                 INSPEC enhanced with 1898-1968 archive
NEWS EXPRESS
              JUNE 30 CURRENT WINDOWS VERSION IS V8.01b, CURRENT
```

NEWS EXPRESS JUNE 30 CURRENT WINDOWS VERSION IS V8.01b, CURRENT MACINTOSH VERSION IS V6.0c(ENG) AND V6.0Jc(JP), AND CURRENT DISCOVER FILE IS DATED 26 JUNE 2006.

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NEWS LOGIN Welcome Banner and News Items
NEWS IPC8 For general information regarding STN implementation of IPC 8
NEWS X25 X.25 communication option no longer available

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=> file reg COST IN U.S. DOLLARS

SINCE FILE TOTAL ENTRY SESSION 0.21 0.21

FULL ESTIMATED COST

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http://www.cas.org/ONLINE/UG/regprops.html

=>Testing the current file.... screen

ENTER SCREEN EXPRESSION OR (END):end

=> screen 970

L1 SCREEN CREATED

=> screen 1992 OR 2016 OR 2021 OR 2026 OR 1938 OR 1958 OR 1985 OR 1839

L2 SCREEN CREATED

=>

Uploading C:\Documents and Settings\rkeys\My
Documents\STNEXP4\TEMPLATE\STANDARD\10533788a.str



chain nodes :
1 2 3 10
ring nodes :
4 5 6 7 8 9
chain bonds :
1-2 2-3 3-4
ring bonds :
4-5 4-9 5-6 6-7 7-8 8-9

```
10/533,788
```

exact/norm bonds :

2-3 3-4

exact bonds :

1-2 4-5 4-9 5-6 6-7 7-8 8-9

isolated ring systems :

containing 4:

Match level:

1:CLASS 2:CLASS 3:CLASS 4:Atom 5:Atom 6:Atom 7:Atom 8:Atom 9:Atom 10:CLASS 11:CLASS

L3 STRUCTURE UPLOADED

=> que L3 AND L1 NOT L2

L4 QUE L3 AND L1 NOT L2

=> d

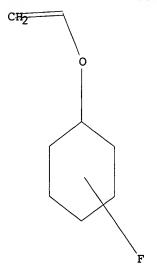
L4 HAS NO ANSWERS

L1 SCR 970

L2 SCR 1992 OR 2016 OR 2021 OR 2026 OR 1938 OR 1958 OR 1985 O

R 1839

L3 STR



Structure attributes must be viewed using STN Express query preparation. L4 QUE L3 AND L1 NOT L2

=> s 14

SAMPLE SEARCH INITIATED 23:24:48 FILE 'REGISTRY'
SAMPLE SCREEN SEARCH COMPLETED - 16 TO ITERATE

100.0% PROCESSED 16 ITERATIONS

0 ANSWERS

SEARCH TIME: 00.00.01

FULL FILE PROJECTIONS: ONLINE **COMPLETE**

BATCH **COMPLETE**

PROJECTED ITERATIONS: 80 TO 560 PROJECTED ANSWERS: 0 TO 0

L50 SEA SSS SAM L3 AND L1 NOT L2

=> s 14 ful

FULL SEARCH INITIATED 23:24:55 FILE 'REGISTRY' FULL SCREEN SEARCH COMPLETED - 423 TO ITERATE

100.0% PROCESSED

423 ITERATIONS

0 ANSWERS

SEARCH TIME: 00.00.01

0 SEA SSS FUL L3 AND L1 NOT L2 L6

=>Testing the current file.... screen

ENTER SCREEN EXPRESSION OR (END):end

=> screen 970

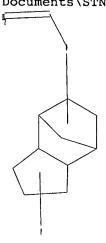
SCREEN CREATED L7

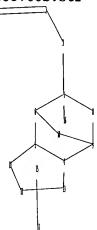
=> screen 1992 OR 2016 OR 2021 OR 2026 OR 1938 OR 1958 OR 1985

SCREEN CREATED L8

=>

Uploading C:\Documents and Settings\rkeys\My Documents\STNEXP4\TEMPLATE\STANDARD\10533788b.str





chain nodes : 1 2 3 14 ring nodes : 4 5 6 7 8 9 10 11 12 13

chain bonds :

1-2 2-3

ring bonds :

4-5 4-9 4-13 5-6 5-11 6-7 6-10 7-8 8-9 9-10 11-12 12-13

exact/norm bonds :

2-3

exact bonds:

1-2 4-5 4-9 4-13 5-6 5-11 6-7 6-10 7-8 8-9 9-10 11-12 12-13

isolated ring systems :

containing 4:

Match level:

1:CLASS 2:CLASS 3:CLASS 4:Atom 5:Atom 6:Atom 7:Atom 8:Atom 9:Atom 10:CLASS 11:Atom 12:Atom 13:Atom 14:CLASS 15:CLASS 16:CLASS

L9 STRUCTURE UPLOADED

=> que L9 AND L7 NOT L8

L10 QUE L9 AND L7 NOT L8

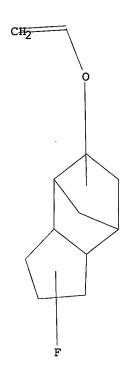
=> d

L10 HAS NO ANSWERS

L7 SCR 970

L8 SCR 1992 OR 2016 OR 2021 OR 2026 OR 1938 OR 1958 OR 1985

L9 STR



Structure attributes must be viewed using STN Express query preparation. L10 QUE L9 AND L7 NOT L8

=> s 110

SAMPLE SEARCH INITIATED 23:26:02 FILE 'REGISTRY'
SAMPLE SCREEN SEARCH COMPLETED - 14 TO ITERATE

100.0% PROCESSED 14 ITERATIONS 1 ANSWERS

SEARCH TIME: 00.00.01

FULL FILE PROJECTIONS: ONLINE **COMPLETE**
BATCH **COMPLETE**
PROJECTED ITERATIONS: 56 TO 504

PROJECTED ITERATIONS: 56 TO 504
PROJECTED ANSWERS: 1 TO 80

L11 1 SEA SSS SAM L9 AND L7 NOT L8

=> s 110 ful

FULL SEARCH INITIATED 23:26:08 FILE 'REGISTRY'
FULL SCREEN SEARCH COMPLETED - 315 TO ITERATE

100.0% PROCESSED

315 ITERATIONS

8 ANSWERS

SEARCH TIME: 00.00.01

L12

8 SEA SSS FUL L9 AND L7 NOT L8

=> d scan

L12 8 ANSWERS REGISTRY COPYRIGHT 2006 ACS on STN

IN 2-Propenoic acid, 2-(trifluoromethyl)-, polymer with α,αbis(trifluoromethyl)bicyclo[2.2.1]hept-5-ene-2-ethanol,
5-(ethenyloxy)-1,1,2,2,3,3,3a,7a-octafluorooctahydro-4,7-methano-1H-indene
and tetrafluoroethene, 1-[[3,5-bis[2,2,2-trifluoro-1-hydroxy-1 (trifluoromethyl)ethyl]cyclohexyl]oxy]ethyl ester (9CI)
MF C14 H16 F12 O4 . x (C12 H10 F8 O . C11 H12 F6 O . C4 H3 F3 O2 . C2 F4)x

CM 1

CM 2

CM 3

CM 4

CM 5

CM 6

HOW MANY MORE ANSWERS DO YOU WISH TO SCAN? (1):0

=> file caplus
COST IN U.S. DOLLARS

SINCE FILE TOTAL ENTRY SESSION 334.32 334.53

FULL ESTIMATED COST

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=> d his

(FILE 'HOME' ENTERED AT 23:24:09 ON 22 AUG 2006)

```
FILE 'REGISTRY' ENTERED AT 23:24:24 ON 22 AUG 2006
L1
               SCREEN 970
L2
               SCREEN 1992 OR 2016 OR 2021 OR 2026 OR 1938 OR 1958 OR 19
L3
               STRUCTURE UPLOADED
L4
               QUE L3 AND L1 NOT L2
L5
             0 S L4
L6
             0 S L4 FUL
L7
               SCREEN 970
rs
               SCREEN 1992 OR 2016 OR 2021 OR 2026 OR 1938 OR 1958 OR 19
L9
               STRUCTURE UPLOADED
```

```
10/533,788
```

L10 QUE L9 AND L7 NOT L8

L11 1 S L10 L12 8 S L10 FUL

FILE 'CAPLUS' ENTERED AT 23:26:27 ON 22 AUG 2006

=> s 112

L13 2 L12

=> dup rem 113

PROCESSING COMPLETED FOR L13

L14 2 DUP REM L13 (0 DUPLICATES REMOVED)

=> d 1-2 bib fhitstr

L14 ANSWER 1 OF 2 CAPLUS COPYRIGHT 2006 ACS on STN

2004:412905 CAPLUS ΑN

DN 140:424105

TI Fluorine-containing vinyl ethers, their polymers, and resist compositions using such polymers

IN Kobayashi, Satoru; Maeda, Kazuhiko; Tsujishita, Tooru

PA Central Glass Company, Limited, Japan

SO PCT Int. Appl., 45 pp.

CODEN: PIXXD2

DTPatent

LA English

FAN. CNT 1

L WIM	CNII						
	PATENT NO.	KIND	DATE	APPLICATION NO.	DATE		
PΙ	WO 2004041762	A1	20040521	WO 2003-JP13924	20031030		
	W: KR, US						
	JP 2004155680	A2	20040603	JP 2002-320871	20021105		
	JP 2004231815	A2	20040819	JP 2003-22925	20030131		
	US 2006074263	A1	20060406	US 2005-533788	20050504		
PRAI	JP 2002-320871	Α	20021105				
	JP 2003-22925	Α	20030131				
	WO 2003-JP13924	W	20031030				
os	MARPAT 140:424105						

IT 691870-38-9P

> RL: IMF (Industrial manufacture); PREP (Preparation) (fluorine-containing vinyl ethers, their polymers, and resist compns. using such polymers)

691870-38-9 CAPLUS RN

CN 4,7-Methano-1H-indene, 5-(ethenyloxy)-1,1,2,2,3,3,3a,7aoctafluorooctahydro-, homopolymer (9CI) (CA INDEX NAME)

CM 1

CRN 691870-36-7 CMF C12 H10 F8 O

```
L14 ANSWER 2 OF 2 CAPLUS COPYRIGHT 2006 ACS on STN
AN
     2004:758843 CAPLUS
DN
ΤI
     Fluorine compounds bearing acid-labile groups, their manufacture, and
     photoresists, and pattern forming method using the photoresists
     Yamaoka, Tsugio; Maeda, Kazuhiko
IN
     Central Glass Co., Ltd., Japan
PA
     Jpn. Kokai Tokkyo Koho, 21 pp.
SO
     CODEN: JKXXAF
DΤ
     Patent
     Japanese
LA
FAN.CNT 1
     PATENT NO.
                        KIND
                                DATE
                                            APPLICATION NO.
                                                                   DATE
                        ____
                                _____
                                            -----
                                                                   _____
     JP 2004256562
                         A2
                                20040916
                                            JP 2003-45329
                                                                   20030224
PRAI JP 2003-45329
                                20030224
     754211-83-1P
     RL: IMF (Industrial manufacture); TEM (Technical or engineered material
     use); PREP (Preparation); USES (Uses)
        (manufacture of fluorine compds. bearing acid-labile groups and showing good
        etching resistance for vacuum-UV photoresists)
     754211-83-1 CAPLUS
RN
CN
     2-Propenoic acid, 2-(trifluoromethyl)-, polymer with 5-(ethenyloxy)-
     1,1,2,2,3,3,3a,7a-octafluorooctahydro-4,7-methano-1H-indene,
     5-(ethenyloxy)-\alpha, \alpha, \alpha', \alpha'-tetrakis(trifluoromethyl)-
     1,3-cyclohexanedimethanol and 5(or 6)-[3,3,3-trifluoro-2-hydroxy-2-
     (trifluoromethyl)propyl]bicyclo[2.2.1]hept-2-yl 2-(trifluoromethyl)-2-
     propenoate, 1-[[5(or 6)-[2,2,2-trifluoro-1-hydroxy-1-
     (trifluoromethyl)ethyl]bicyclo[2.2.1]hept-2-yl]oxy]ethyl ester (9CI) (CA
     INDEX NAME)
     CM
          1
     CRN
         754211-82-0
         C12 H16 F6 O3
     CMF
     CCI IDS
       OH
         CF3
       CF<sub>3</sub>
      OH
D1-O-CH-Me
    CM
    CRN
         754211-81-9
    CMF
          (C15 H15 F9 O3 . C14 H14 F12 O3 . C12 H10 F8 O . C4 H3 F3 O2)x
    CCI
         CM
               3
         CRN 691870-36-7
```

CMF C12 H10 F8 O

CM 4

CRN 691410-53-4 CMF C14 H14 F12 O3

$$F_3C-C$$
 CF_3
 $C-CF_3$
 $C-CF_3$
 $C-CF_3$
 $C-CF_3$
 $C-CF_3$
 $C-CF_3$

CM 5

CRN 585571-44-4 CMF C15 H15 F9 O3 CCI IDS

CM 6

CRN 381-98-6 CMF C4 H3 F3 O2

=> file reg
COST IN U.S. DOLLARS

FULL ESTIMATED COST

SINCE FILE TOTAL ENTRY SESSION 7.94 342.47

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=>Testing the current file.... screen

ENTER SCREEN EXPRESSION OR (END):end

=> screen 970

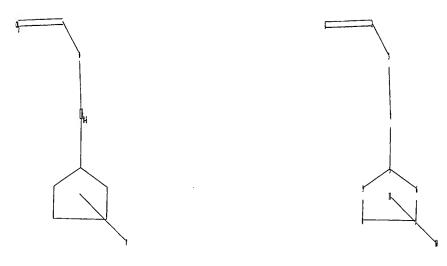
L15 SCREEN CREATED

=> screen 1992 OR 2016 OR 2021 OR 2026 OR 1938 OR 1958 OR 1985 OR 1839

L16 SCREEN CREATED

=>

Uploading C:\Documents and Settings\rkeys\My
Documents\STNEXP4\TEMPLATE\STANDARD\10533788c.str



chain nodes:
1 2 3 4 10
ring nodes:
5 6 7 8 9
chain bonds:
1-2 2-3 3-4 4-5
ring bonds:
5-6 5-9 6-7 7-8 8-9
exact/norm bonds:
2-3 3-4
exact bonds:
1-2 4-5 5-6 5-9 6-7 7-8 8-9
isolated ring systems:
containing 5:

Match level:
1:CLASS 2:CLASS 3:CLASS 4:CLASS 5:Atom 6:Atom 7:Atom 8:Atom 9:Atom 10:CLASS 11:CLASS

L17 STRUCTURE UPLOADED

=> que L17 AND L15 NOT L16

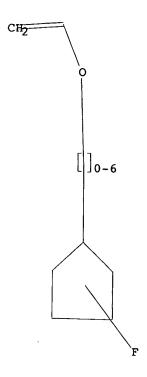
L18 QUE L17 AND L15 NOT L16

=> d L18 HAS NO ANSWERS L15 SCR

L16 SCR 1992 OR 2016 OR 2021 OR 2026 OR 1938 OR 1958 OR 1985 O

R 1839

L17 STR



Structure attributes must be viewed using STN Express query preparation. L18 QUE L17 AND L15 NOT L16

=> s 118

SAMPLE SEARCH INITIATED 23:28:14 FILE 'REGISTRY'
SAMPLE SCREEN SEARCH COMPLETED - 4 TO ITERATE

100.0% PROCESSED 4 ITERATIONS 0 ANSWERS

SEARCH TIME: 00.00.01

FULL FILE PROJECTIONS: ONLINE **COMPLETE**
BATCH **COMPLETE**

PROJECTED ITERATIONS: 4 TO 200 PROJECTED ANSWERS: 0 TO 0

L19 0 SEA SSS SAM L17 AND L15 NOT L16

=> s 118 ful

FULL SEARCH INITIATED 23:28:19 FILE 'REGISTRY'
FULL SCREEN SEARCH COMPLETED - 80 TO ITERATE

100.0% PROCESSED 80 ITERATIONS 0 ANSWERS

SEARCH TIME: 00.00.01

L20 0 SEA SSS FUL L17 AND L15 NOT L16

=>Testing the current file.... screen

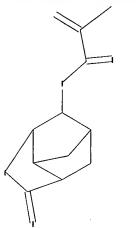
ENTER SCREEN EXPRESSION OR (END):end

=> screen 1992 OR 2016 OR 2021 OR 2026 OR 1938 OR 1958 OR 1985

L21 SCREEN CREATED

=>

Uploading C:\Documents and Settings\rkeys\My Documents\STNEXP4\TEMPLATE\STANDARD\10533788d.str



chain nodes :

1 2 3 4 5 6 16

ring nodes :

7 8 9 10 11 12 13 14 15

chain bonds :

1-2 2-3 2-4 4-5 4-6 6-7 15-16

ring bonds :

7-8 7-12 8-9 8-13 9-10 10-11 10-15 11-12 11-13 12-14 14-15

exact/norm bonds :

4-5 4-6 6-7 15-16

exact bonds :

1-2 2-3 2-4 7-8 7-12 8-9 8-13 9-10 10-11 10-15 11-12 11-13 12-14 14-15

isolated ring systems:

containing 7:

Match level:

1:CLASS 2:CLASS 3:CLASS 4:CLASS 5:CLASS 6:CLASS 7:Atom 8:Atom 9:Atom

10:Atom 11:Atom 12:Atom 13:Atom 14:Atom 15:Atom 16:CLASS

L22 STRUCTURE UPLOADED

=> que L22 NOT L21

L23 QUE L22 NOT L21

SAMPLE SEARCH INITIATED 23:28:57 FILE 'REGISTRY' SAMPLE SCREEN SEARCH COMPLETED -61 TO ITERATE

100.0% PROCESSED

61 ITERATIONS

31 ANSWERS

SEARCH TIME: 00.00.01

FULL FILE PROJECTIONS: ONLINE **COMPLETE**

BATCH **COMPLETE**

PROJECTED ITERATIONS: PROJECTED ANSWERS:

752 TO 1688 286 TO 954 L24 31 SEA SSS SAM L22 NOT L21

=> s 123 ful

FULL SEARCH INITIATED 23:29:30 FILE 'REGISTRY'
FULL SCREEN SEARCH COMPLETED - 1115 TO ITERATE

100.0% PROCESSED 1115 ITERATIONS 641 ANSWERS

SEARCH TIME: 00.00.01

L25 641 SEA SSS FUL L22 NOT L21

=> file caplus

COST IN U.S. DOLLARS
SINCE FILE TOTAL
ENTRY SESSION
FULL ESTIMATED COST
334.32
676.79

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=> s 125 and (fluor? (10a) vinyl ether) 388 L25 1153580 FLUOR? 406157 VINYL

482524 ETHER

20284 VINYL ETHER

(VINYL(W)ETHER)

2178 FLUOR? (10A) VINYL ETHER

L26 2 L25 AND (FLUOR? (10A) VINYL ETHER)

=> d 1-2 ti

L26 ANSWER 1 OF 2 CAPLUS COPYRIGHT 2006 ACS on STN

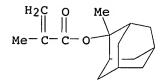
TI Fluorine-containing vinyl ethers, their polymers, and resist compositions using such polymers

L26 ANSWER 2 OF 2 CAPLUS COPYRIGHT 2006 ACS on STN

TI Fluoro-functional acid generators and acid generator-containing radiation-sensitive resin compositions suitable for lithography

```
L26
    ANSWER 2 OF 2 CAPLUS COPYRIGHT 2006 ACS on STN
    2003:4859 CAPLUS
ΑN
DN
    138:56869
    Fluoro-functional acid generators and acid generator-containing
TI
    radiation-sensitive resin compositions suitable for lithography
IN
    Ebata, Satoshi; Yoneda, Eiji; Nagai, Tomoki; Toneri, Tatsuya; Wang, Yong;
    Iwasawa, Haruo; Nishimura, Yukio
PA
    JSR Corporation, Japan
SO
    Eur. Pat. Appl., 100 pp.
    CODEN: EPXXDW
DΤ
    Patent
LA
    English
FAN.CNT 1
    PATENT NO.
                       KIND
                               DATE
                                          APPLICATION NO.
                                                                 DATE
                        ____
                               -----
                                          -----
                                                                  _____
PΙ
    EP 1270553
                                          EP 2002-14416
                        A2
                               20030102
                                                                  20020628
    EP 1270553
                        A3
                              20040421
        R: AT, BE, CH, DE, DK, ES, FR, GB, GR, IT, LI, LU, NL, SE, MC, PT,
            IE, SI, LT, LV, FI, RO, MK, CY, AL, TR
    JP 2003173027
                               20030620
                        A2
                                           JP 2001-371311
                                                                  20011205
    US 2003113658
                               20030619
                        A1
                                           US 2002-183441
                                                                  20020628
    US 6908722
                        В2
                               20050621
    CN 1432873
                        Α
                               20030730
                                           CN 2002-160643
                                                                  20020628
    JP 2004002252
                       A2
                               20040108
                                           JP 2002-189133
                                                                  20020628
    US 2003170561
                               20030911
                        A1
                                           US 2002-309017
                                                                  20021204
    JP 2006133803
                        A2
                               20060525
                                          JP 2006-5710
                                                                 20060113
PRAI JP 2001-200154
                        Α
                               20010629
    JP 2001-371311
                         Α
                               20011205
    JP 2002-81235
                         Α
                               20020322
IT
    340964-24-1P
    RL: CPS (Chemical process); IMF (Industrial manufacture); PEP (Physical,
    engineering or chemical process); POF (Polymer in formulation); PRP
    (Properties); PYP (Physical process); TEM (Technical or engineered
    material use); PREP (Preparation); PROC (Process); USES (Uses)
        (acid-cleavable group-containing resin; fluoro-functional acid generators
       and acid generator-containing radiation-sensitive resin compns. suitable
        for lithog.)
RN
    340964-24-1 CAPLUS
CN
    2-Propenoic acid, 2-methyl-, hexahydro-2-oxo-3,5-methano-2H-
    cyclopenta[b]furan-6-yl ester, polymer with 2-
    methyltricyclo[3.3.1.13,7]dec-2-yl 2-methyl-2-propenoate (9CI) (CA INDEX
    NAME)
    CM
         1
    CRN 254900-07-7
    CMF C12 H14 O4
              CH<sub>2</sub>
         0-C-C-Me
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CRN 177080-67-0 CMF C15 H22 O2



=>
=> file reg
COST IN U.S. DOLLARS

FULL ESTIMATED COST

SINCE FILE TOTAL ENTRY SESSION 11.86 688.65

FILE 'REGISTRY' ENTERED AT 23:31:44 ON 22 AUG 2006 USE IS SUBJECT TO THE TERMS OF YOUR STN CUSTOMER AGREEMENT. PLEASE SEE "HELP USAGETERMS" FOR DETAILS. COPYRIGHT (C) 2006 American Chemical Society (ACS)

Property values tagged with IC are from the ZIC/VINITI data file provided by InfoChem.

STRUCTURE FILE UPDATES: 21 AUG 2006 HIGHEST RN 903048-34-0 DICTIONARY FILE UPDATES: 21 AUG 2006 HIGHEST RN 903048-34-0

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REGISTRY includes numerically searchable data for experimental and predicted properties as well as tags indicating availability of experimental property data in the original document. For information on property searching in REGISTRY, refer to:

http://www.cas.org/ONLINE/UG/regprops.html

=>Testing the current file.... screen

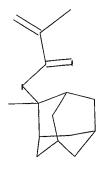
ENTER SCREEN EXPRESSION OR (END):end

=> screen 1992 OR 2016 OR 2021 OR 2026 OR 1938 OR 1958 OR 1985

L27 SCREEN CREATED

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Uploading C:\Documents and Settings\rkeys\My
Documents\STNEXP4\TEMPLATE\STANDARD\10533788e.str



chain nodes :
1 2 3 4 5 6 17
ring nodes :
7 8 9 10 11 12 13 14 15 16
chain bonds :
1-2 2-3 2-4 4-5 4-6 6-7 7-17
ring bonds :
7-8 7-9 8-14 8-15 9-10 9-16 10-11 11-12 11-15 12-13 13-14 13-16
exact/norm bonds :
4-5 4-6 6-7 7-8 7-9 8-14 8-15 9-10 9-16 10-11 11-12 11-15 12-13 13-14
13-16
exact bonds :
1-2 2-3 2-4 7-17

Match level:
1:CLASS 2:CLASS 3:CLASS 4:CLASS 5:CLASS 6:CLASS 7:Atom 8:Atom 9:Atom 10:Atom 11:Atom 12:Atom 13:Atom 14:Atom 15:Atom 16:Atom 17:CLASS

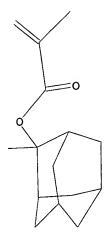
L28 STRUCTURE UPLOADED

=> que L28 NOT L27

L29 QUE L28 NOT L27

=> d L29 HAS NO ANSWERS L27 SCR 1992 OR 2016 OR 2021 OR 2026 OR 1938 OR 1958 OR 1985

L28 STR



Structure attributes must be viewed using STN Express query preparation. L29 QUE L28 NOT L27

=> s 129

SAMPLE SEARCH INITIATED 23:32:12 FILE 'REGISTRY'
SAMPLE SCREEN SEARCH COMPLETED - 181 TO ITERATE

100.0% PROCESSED

181 ITERATIONS

50 ANSWERS

INCOMPLETE SEARCH (SYSTEM LIMIT EXCEEDED)

SEARCH TIME: 00.00.01

FULL FILE PROJECTIONS:

ONLINE **COMPLETE**

BATCH **COMPLETE**

PROJECTED ITERATIONS:

2813 TO 4427

PROJECTED ANSWERS:

1114 TO 2206

L30

50 SEA SSS SAM L28 NOT L27

=> s 129 ful

FULL SEARCH INITIATED 23:32:18 FILE 'REGISTRY'
FULL SCREEN SEARCH COMPLETED - 3088 TO ITERATE

100.0% PROCESSED

3088 ITERATIONS

1469 ANSWERS

SEARCH TIME: 00.00.01

L31

1469 SEA SSS FUL L28 NOT L27

=> file caplus

COST IN U.S. DOLLARS

SINCE FILE

TOTAL

FULL ESTIMATED COST

ENTRY SESSION 166.94 855.59

FILE 'CAPLUS' ENTERED AT 23:32:25 ON 22 AUG 2006

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FILE COVERS 1907 - 22 Aug 2006 VOL 145 ISS 9 FILE LAST UPDATED: 21 Aug 2006 (20060821/ED)

Effective October 17, 2005, revised CAS Information Use Policies apply. They are available for your review at:

http://www.cas.org/infopolicy.html

9 L31 AND (FLUOR? (10A) VINYL ETHER)

=> d 1-9 ti

L32

- L32 ANSWER 1 OF 9 CAPLUS COPYRIGHT 2006 ACS on STN
- TI Positive-working photoresist composition containing alkali-soluble fluorine-containing polymer
- L32 ANSWER 2 OF 9 CAPLUS COPYRIGHT 2006 ACS on STN
- TI The chemically amplified photoresist composition and the pattern formation method
- L32 ANSWER 3 OF 9 CAPLUS COPYRIGHT 2006 ACS on STN
- TI Positive resist composition
- L32 ANSWER 4 OF 9 CAPLUS COPYRIGHT 2006 ACS on STN
- TI Fluorine compounds bearing acid-labile groups, their manufacture, and photoresists, and pattern forming method using the photoresists
- L32 ANSWER 5 OF 9 CAPLUS COPYRIGHT 2006 ACS on STN
- TI Chemically amplified resist composition, its manufacture, and patterning method
- L32 ANSWER 6 OF 9 CAPLUS COPYRIGHT 2006 ACS on STN
- TI Fluorine-containing vinyl ethers, their polymers, and resist compositions using such polymers
- L32 ANSWER 7 OF 9 CAPLUS COPYRIGHT 2006 ACS on STN
- TI Positive resist compositions using fluorine-containing copolymers
- L32 ANSWER 8 OF 9 CAPLUS COPYRIGHT 2006 ACS on STN
- TI Fluoro-functional acid generators and acid generator-containing radiation-sensitive resin compositions suitable for lithography
- L32 ANSWER 9 OF 9 CAPLUS COPYRIGHT 2006 ACS on STN
- TI Photoresist compositions comprising fluorinated phenolic polymers
- => s 132 and 1700-2003/py 23862367 1700-2003/PY
- L33 3 L32 AND 1700-2003/PY

=> d 1-3 bib fhitstr

L33 ANSWER 1 OF 3 CAPLUS COPYRIGHT 2006 ACS on STN

AN 2003:582472 CAPLUS

DN 139:140963

TI Positive resist compositions using fluorine-containing copolymers

IN Maeda, Kazuhiko; Komoritani, Haruhiko; Yamanaka, Kazuhiro

PA Central Glass Co., Ltd., Japan

SO Jpn. Kokai Tokkyo Koho, 12 pp.

CODEN: JKXXAF
DT Patent

LA Japanese

FAN.CNT 1

PATENT NO.	KIND	DATE	APPLICATION NO.	DATE			
PI JP 2003212915 PRAI JP 2002-10909	A2	20030730 20020118	JP 2002-10909	20020118 <			

IT 568587-23-5P

RL: IMF (Industrial manufacture); TEM (Technical or engineered material use); PREP (Preparation); USES (Uses)

(pos. resist compns. using fluoroalkyl acrylate-vinyl ether copolymers and acid generators for high transparency)

RN 568587-23-5 CAPLUS

CN 2-Propenoic acid, 2-(trifluoromethyl)-, 2-methyltricyclo[3.3.1.13,7]dec-2-yl ester, polymer with 1-(ethenyloxy)-1,1,2,2,3,3,4,4,5,5,6,6,7,7,8,8,8-heptadecafluorooctane (9CI) (CA INDEX NAME)

CM 1

CRN 188739-86-8 CMF C15 H19 F3 O2

CM 2

CRN 60321-80-4 CMF C10 H3 F17 O

 $H_2C = CH - O - (CF_2)_7 - CF_3$

- L33 ANSWER 2 OF 3 CAPLUS COPYRIGHT 2006 ACS on STN
- AN 2003:4859 CAPLUS
- DN 138:56869
- TI Fluoro-functional acid generators and acid generator-containing radiation-sensitive resin compositions suitable for lithography
- IN Ebata, Satoshi; Yoneda, Eiji; Nagai, Tomoki; Toneri, Tatsuya; Wang, Yong; Iwasawa, Haruo; Nishimura, Yukio
- PA JSR Corporation, Japan
- SO Eur. Pat. Appl., 100 pp. CODEN: EPXXDW

DT Patent LA English FAN.CNT 1

		_															
	PATENT NO.			KIND DATE			API	APPLICATION NO.					DATE				
ΡI	EP	P 1270553 P 1270553		A2 20030102			EP 2002-14416					20020628 <			<		
	ΕP			A 3	2004	0421											
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			ΙE,	SI,	LT,	LV,	FI, RO,	MK,	CY, AI	TR							
	JΡ	20031	7302	27		A2	2003	30620	JP	2001-	37131	1		20	0112	205	<
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	CN	14328	73			Α	2003	30730	CN	2002-	16064	3		20	0206	528	<
	JP	20040	0225	52		A2	2004	0108	JP	2002-	18913	3		20	0206	528	
	US	20031	7056	51		A 1	2003	30911	US	2002-	30901	7		20	0212	204	<
	JΡ	20061	3380	3		A2	2006	0525	JP	2006-	5710			20	0601	13	
PRAI	JΡ	2001-	2001	.54		A	2001	0629									
	JP	2001-	3713	311		Α	2001	1205									
	JΡ	2002-	8123	35		Α	2002	0322									

IT 330576-44-8P

RL: CPS (Chemical process); IMF (Industrial manufacture); PEP (Physical, engineering or chemical process); POF (Polymer in formulation); PRP (Properties); PYP (Physical process); TEM (Technical or engineered material use); PREP (Preparation); PROC (Process); USES (Uses)

(acid-cleavable group-containing resin; fluoro-functional acid generators and acid generator-containing radiation-sensitive resin compns. suitable for lithog.)

RN 330576-44-8 CAPLUS

CN 2-Propenoic acid, 2-methyl-, 2-methyltricyclo[3.3.1.13,7]dec-2-yl ester, polymer with bicyclo[2.2.1]hept-2-ene, 2,5-furandione and 1,2,3,4,4a,5,8,8a-octahydro-1,4:5,8-dimethanonaphthalen-2-ol (9CI) (CA INDEX NAME)

CM 1

CRN 177080-67-0 CMF C15 H22 O2

CM 2

CRN 7388-87-6 CMF C12 H16 O

498-66-8 CRN CMF C7 H10



CM

CRN 108-31-6 C4 H2 O3 CMF

2002:185456 CAPLUS

L33 ANSWER 3 OF 3 CAPLUS COPYRIGHT 2006 ACS on STN

CM

1

AN

DN

```
136:254545
ΤI
      Photoresist compositions comprising fluorinated phenolic polymers
      Klauck-Jacobs, Axel; Zampini, Anthony; Cho, Sungseo; Yamada, Shintaro
IN
PA
      Shipley Company, L.L.C., USA
SO
      PCT Int. Appl., 42 pp.
      CODEN: PIXXD2
DT
      Patent
     English
LA
FAN.CNT 2
      PATENT NO.
                              KIND
                                       DATE
                                                     APPLICATION NO.
                                                                                  DATE
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                              ----
                                       _____
                                                      -----
PΙ
      WO 2002021212
                               A2
                                       20020314
                                                     WO 2001-US28184
                                                                                  20010908 <--
      WO 2002021212
                               A3
                                       20020822
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               HU, ID, IL, IN, IS, JP, KE, KG, KP, KR, KZ, LC, LK, LR, LS, LT, LU, LV, MA, MD, MG, MK, MN, MW, MX, MZ, NO, NZ, PL, PT, RO, RU, SD, SE, SG, SI, SK, SL, TJ, TM, TR, TT, TZ, UA, UG, UZ, VN, YU, ZA, ZW, AM, AZ, BY, KG, KZ, MD, RU, TJ, TM
          RW: GH, GM, KE, LS, MW, MZ, SD, SL, SZ, TZ, UG, ZW, AT, BE, CH, CY, DE, DK, ES, FI, FR, GB, GR, IE, IT, LU, MC, NL, PT, SE, TR, BF, BJ, CF, CG, CI, CM, GA, GN, GQ, GW, ML, MR, NE, SN, TD, TG
      AU 2001087147
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                                                                                  20010908 <--
      US 2002058198
                                                      US 2001-948521
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                                       20020516
                                                                                  20010908 <--
      US 2002058199
                                                      US 2001-948903
                               A1
                                       20020516
                                                                                  20010908 <--
PRAI US 2000-231274P
                               Ρ
                                       20000908
      US 2000-253118P
                               Ρ
                                       20001127
     WO 2001-US28184
                               W
                                       20010908
IT
      403814-70-0P
     RL: PRP (Properties); SPN (Synthetic preparation); PREP (Preparation)
          (photoresist compns. comprising fluorinated phenolic polymers)
RN
      403814-70-0 CAPLUS
CN
      2-Propenoic acid, 2-methyl-, 2-methyltricyclo[3.3.1.13,7]dec-2-yl ester,
     polymer with 4-ethenyl-2,3,5,6-tetrafluorophenol (9CI) (CA INDEX NAME)
```

CRN 385422-30-0 CMF C8 H4 F4 O

$$F$$
 $CH = CH_2$
 F

CM 2

CRN 177080-67-0 CMF C15 H22 O2

=> log hold COST IN U.S. DOLLARS

FULL ESTIMATED COST

SINCE FILE TOTAL ENTRY SESSION 22.68 878.27

SESSION WILL BE HELD FOR 60 MINUTES
STN INTERNATIONAL SESSION SUSPENDED AT 23:34:23 ON 22 AUG 2006